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Notice of Allowability	Application No.	Applicant(s)		
	10/608,229	PARK ET AL.		
	Examiner	Art Unit		
	Matt P. Hodges	2879		
The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS (herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT Report of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this app or other appropriate communication GHTS. This application is subject to	olication. If not include will be mailed in due	ed course. <b>THIS</b>	
1. A This communication is responsive to amendment filed 2/17.	<u>/2006</u> .			
2. The allowed claim(s) is/are <u>1-20</u> .	•			
<ol> <li>Acknowledgment is made of a claim for foreign priority un a)</li></ol>	been received.  been received in Application No cuments have been received in this r	national stage applica		
4. A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which give			IOTICE OF	
<ol> <li>CORRECTED DRAWINGS ( as "replacement sheets") mus (a)  including changes required by the Notice of Draftspers 1)  hereto or 2)  to Paper No./Mail Date</li> <li>(b)  including changes required by the attached Examiner's Paper No./Mail Date</li> </ol>	on's Patent Drawing Review ( PTO-9	,		
ldentifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in th			back) of	
6. DEPOSIT OF and/or INFORMATION about the depose attached Examiner's comment regarding REQUIREMENT F			Note the	
Attachment(a)				
Attachment(s) 1. ☐ Notice of References Cited (PTO-892)	5. Notice of Informal Pa	atent Application (PT	O-152)	
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Summary	6. Interview Summary (PTO-413),		
3. Information Disclosure Statements (PTO-1449 or PTO/SB/0-Paper No./Mail Date	Paper No./Mail Date 8), 7. ☐ Examiner's Amendm	Paper No./Mail Date  7.  Examiner's Amendment/Comment		
<ol> <li>Examiner's Comment Regarding Requirement for Deposit of Biological Material</li> </ol>	8. ⊠ Examiner's Stateme 9. □ Other	nt of Reasons for Allo	wance	
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## **DETAILED ACTION**

## Response to Amendment

The Amendment, filed on 2/17/2006, has been entered and acknowledged by the Examiner.

## Allowable Subject Matter

Claims 1-20 are allowed.

The following is an examiner's statement of reasons for allowance:

Regarding claim 1, the references of the Prior Art of record fails to teach or suggest the combination of the limitations as set forth in claim 1, and specifically comprising the limitation of an active matrix organic EL display device including a first and second connection means between the first and second substrates where the two connection means are of similar construction and the second connection means connects a first electrode at a periphery of the device and further a plurality of first auxiliary electrodes disposed between the pixel regions where the first auxiliary electrodes have a lower resistance than the first electrodes.

Regarding claims 2-11, claims 2-11 are allowable for the reasons given in claim 1 because of their dependency status from claim 1.

Regarding claim 12, the references of the Prior Art of record fails to teach or suggest the combination of the limitations as set forth in claim 12, and specifically comprising the limitation of A method of fabricating an organic electroluminescent device including forming a first insulating layer on a first substrate; forming an active layer on the first insulating layer at each of the plurality of pixel regions, the active layer including polycrystalline silicon and having source



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and drain regions; forming a second insulating layer on the active layer; forming a gate electrode on the second insulating layer over the active layer; forming a third insulating layer on the gate electrode, the third insulating layer having a first contact hole exposing the source region and a second contact hole exposing the drain region, forming source and drain electrodes and a first pad on the third insulating layer, the source electrode being connected to the source region through the first contact hole, the drain electrode being connected to the drain region through the second electrode, and the first pad being disposed at the peripheral region; forming a fourth insulating layer on the source and drain electrodes and the first pad, the fourth insulating layer having a third contact hole exposing the drain electrode, and fourth and fifth contact holes exposing the first pad; forming first and second connection electrodes on the fourth insulating layer, the first connection pattern being connected to the drain electrode through third contact hole, the second connection electrode being connected to the first pad through the fourth contact hole, and attaching the first and second substrates together with a sealant material,

Regarding claims 13-20, claims 13-20 are allowable for the reasons given in claim 12 because of their dependency status from claim 12.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."



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## Contact Information

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Matt P Hodges whose telephone number is (571) 272-2454. The examiner can normally be reached on 7:30 AM to 4:00 PM M-F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nimesh Patel can be reached on (571) 272-2457. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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NIMESHKUMAR D. PATEL
SUPERVISORY PATENT EXAMINER
TECHNOLOGY CENTER 2800